

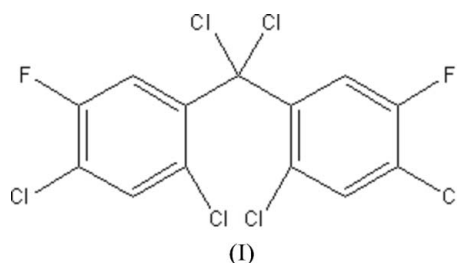
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## Key indicators

Single-crystal X-ray study  
 $T = 298$  K  
Mean  $\sigma(\text{C}-\text{C}) = 0.003$  Å  
 $R$  factor = 0.033  
 $wR$  factor = 0.088  
Data-to-parameter ratio = 12.3For details of how these key indicators were  
automatically derived from the article, see  
<http://journals.iucr.org/e>.Dichlorobis(2,4-dichloro-5-fluorophenyl)-  
methaneThe molecule of the title compound,  $\text{C}_{13}\text{H}_4\text{Cl}_6\text{F}_2$ , has twofold  
crystallographic symmetry, with the axis passing through the  
central methylene C atom. The dihedral angle between the  
two aromatic residues is  $86.13(8)^\circ$ .Received 13 July 2006  
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## Comment

Bis(2,4-dichloro-5-fluorophenyl)dichloromethane, (I), is an  
important intermediate in organic synthesis (Kumai *et al.*,  
1991) and was obtained from the reaction of  $\text{CCl}_4$  and 1,3-  
dichloro-4-fluorobenzene, as colorless crystals suitable for  
X-ray crystallographic analysis.The molecule of (I) has twofold crystallographic symmetry  
(Fig. 1) with the axis passing through the methylene atom C7.  
The dihedral angle between the two aromatic residues is  
 $86.13(8)^\circ$ .

## Experimental

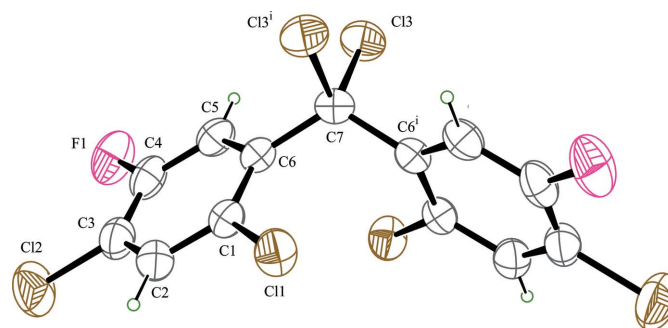
Compound (I) was prepared according to the procedure of Kumai  
*et al.* (1991). A solution of (I) in methanol was concentrated gradually at  
room temperature to afford colorless blocks.

Figure 1

The molecular structure of (I), showing the atom-labeling scheme.  
Displacement ellipsoids are shown at the 30% probability level.  
[Symmetry code: (i)  $x, \frac{1}{2} - y, \frac{1}{2} - z$ .]

*Crystal data*

C<sub>13</sub>H<sub>4</sub>Cl<sub>6</sub>F<sub>2</sub>  
*M<sub>r</sub>* = 410.89  
 Orthorhombic, *Pnna*  
*a* = 19.896 (9) Å  
*b* = 11.483 (4) Å  
*c* = 6.614 (2) Å  
*V* = 1510.9 (10) Å<sup>3</sup>

*Z* = 4  
*D<sub>x</sub>* = 1.806 Mg m<sup>-3</sup>  
 Mo *Kα* radiation  
 $\mu$  = 1.14 mm<sup>-1</sup>  
*T* = 298 (1) K  
 Block, colorless  
 0.43 × 0.33 × 0.30 mm

*Data collection*

Rigaku R-AXIS RAPID  
 diffractometer  
 $\omega$  scans  
 Absorption correction: multi-scan  
 (ABSCOR; Higashi, 1995)  
*T<sub>min</sub>* = 0.613, *T<sub>max</sub>* = 0.710

13211 measured reflections  
 1734 independent reflections  
 1186 reflections with  $F^2 > 2\sigma(F^2)$   
*R<sub>int</sub>* = 0.037  
 $\theta_{\max}$  = 27.5°

*Refinement*

Refinement on  $F^2$   
 $R[F^2 > 2\sigma(F^2)] = 0.033$   
 $wR(F^2) = 0.088$   
*S* = 1.02  
 1189 reflections  
 97 parameters  
 H-atom parameters constrained

$w = 1/[0.0007F_o^2 + \sigma(F_o^2)]/(4F_o^2)$   
 $(\Delta/\sigma)_{\max} < 0.001$   
 $\Delta\rho_{\max} = 0.32 \text{ e \AA}^{-3}$   
 $\Delta\rho_{\min} = -0.33 \text{ e \AA}^{-3}$   
 Extinction correction: Larson  
 (1970), equation 22  
 Extinction coefficient: 40 (2)

The H atoms were included in the riding-model approximation with C–H = 0.93 Å and with  $U_{\text{iso}}(\text{H}) = 1.2U_{\text{eq}}(\text{C})$ .

Data collection: *PROCESS-AUTO* (Rigaku, 1998); cell refinement: *PROCESS-AUTO*; data reduction: *CrystalStructure* (Rigaku/MSK, 2004); program(s) used to solve structure: *SIR97* (Altomare *et al.*, 1993); program(s) used to refine structure: *CRYSTALS* (Betteridge *et al.*, 2003); molecular graphics: *ORTEP-3 for Windows* (Farrugia, 1997); software used to prepare material for publication: *CrystalStructure*.

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